



<b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b> (use as many sheets as necessary)				<b>Complete if Known</b>	
				Application Number	09/295,607
				Filing Date	April 22, 1999
				First Named Inventor	Shunpei YAMAZAKI
				Art Unit	2811
				Examiner Name	Steven Ho Yin Loke
Sheet	1	of	1	Attorney Docket Number	740756-1961

U.S. PATENT DOCUMENTS					
Examiner Initials <sup>1</sup>	Cite No. <sup>1</sup>	U.S. Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number - Kind Code <sup>2</sup> (if known)			
Loke		US-4,832,986	05-23-1989	Gladfelter et al.	
Loke		US-5,192,644	03-09-1993	Ohta et al.	

FOREIGN PATENT DOCUMENTS						
Examiner Initials <sup>1</sup>	Cite No. <sup>1</sup>	Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T <sup>4</sup>
		Country Code <sup>3</sup> Number <sup>4</sup> Kind Code <sup>2</sup> (if known)				
Loke		JP 58-085520	05-21-1983	Koba		Abstract
Loke		JP 62-214669	09-21-1987	Kaneko et al.		Abstract
Loke		JP 02-033935	02-05-1990	Yazaki		Abstract
Loke		JP 03-175632	07-30-1991	Fujiki et al.		Abstract
Loke		JP 04-139727	05-13-1992	Matsumoto et al.		Abstract

OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS			
Examiner Initials <sup>1</sup>	Cite No. <sup>1</sup>	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T <sup>2</sup>
Loke		HSIEH, J.J., ET AL., "DIRECTIONAL DEPOSITION OF DIELECTRIC SILICON OXIDE BY PLASMA ENHANCED TEOS PROCESS", VMIC CONFERENCE, PP. 411-415	

Examiner Signature	Loke	Date Considered	3/2/04
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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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